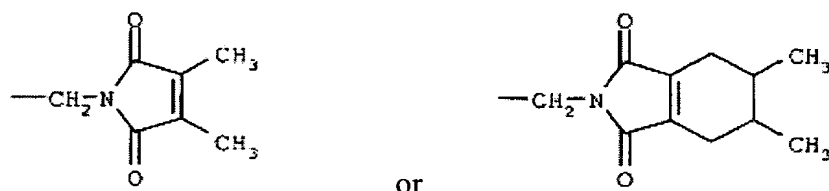
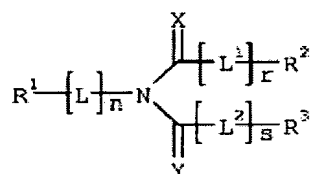


CLAIM AMENDMENTS

1. (Currently Amended) A polymer comprising a phenolic monomeric unit of which the phenyl group is substituted by a group A, characterised in that the wherein group A comprises an imide or thioimide group[[,]] with the exception that A is not

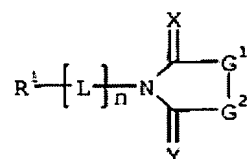


2. (Currently Amended) [[A]] The polymer according to claim 1 wherein the group A has the following formula



wherein X and Y are independently selected from O [[or]] and S,
wherein L, L¹ and L² are independently a linking group,
wherein n, r and s are independently 0 or 1,
and wherein one of the groups R¹, R² or R³ represents the phenolic monomeric unit and the other two represent a terminal group.

3. (Currently Amended) [[A]] The polymer according to claim 1 wherein the group A has the following formula



wherein X and Y are independently selected from O [[or]] and S,

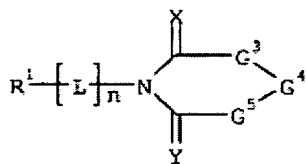
wherein G^1 and G^2 are independently selected from O, S, NR^4 [[or]] and $R^5-[L^3]_t-C-[L^4]_u-R^6$, with the limitation that G^1 is not O or S when G^2 is O and that G^1 is not O or S when G^2 is NR^4 ,

wherein L, L^3 and L^4 are independently a linking group,

wherein n, t and u are independently 0 or 1,

and wherein one of the groups selected from R^1 , R^4 , R^5 [[or]] and R^6 represents the phenolic monomeric unit and the remaining groups represent a terminal group.

4. (Currently amended) [[A]] The polymer according to claim 1 wherein the group A has the following formula



wherein X and Y are independently selected from O [[or]] and S,

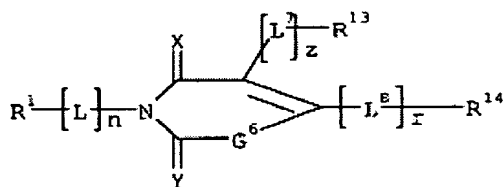
wherein G^3 to G^5 are independently selected from O, S, NR^7 [[or]] and $R^8-[L^5]_v-C-[L^6]_w-R^9$ with the limitation that at least one group, selected from G^3 to G^5 , is $R^8-[L^5]_v-C-[L^6]_w-R^9$ and that two ~~neighbouring~~ neighboring groups, selected from G^3 to G^5 , are not represented by O and S, by O and NR^7 , by S and NR^7 or by O and O,

wherein L, L^5 and L^6 are independently a linking group,

wherein n, v and w are independently 0 or 1, and

wherein one of the groups selected from R^1 , R^7 , R^8 [[or]] and R^9 represents the phenolic monomeric unit and the remaining groups represent a terminal group.

5. (Currently Amended) [[A]] The polymer according to claim 1 wherein the group A has the following formula



wherein X and Y are independently selected from O [[or]] and S,

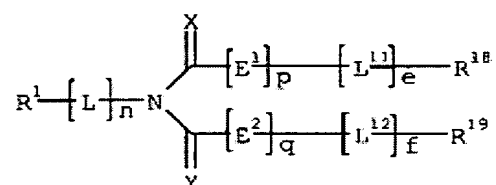
wherein G is a group selected from O, S, NR^{10} [[or]] and $R^{11}-[L^9]_x-C-[L^{10}]_y-R^{12}$,

wherein L , L^7 , L^8 , L^9 and L^{10} are independently a linking group,

wherein n , x , y , z and r are independently 0 or 1, and

wherein one of the groups selected from R^1 , R^{10} , R^{11} , R^{12} , R^{13} and R^{14} represents the phenolic monomeric unit and the remaining groups represent a terminal group.

6. (Currently Amended) [[A]] The polymer according to claim 1 wherein the group A has the following formula



wherein X and Y are independently selected from O [[or]] and S,

wherein E^1 and E^2 are independently selected from O, S, NR^{15} [[or]] and $R^{16} - [L^{13}]_g - C - [L^{14}]_h - R^{17}$,

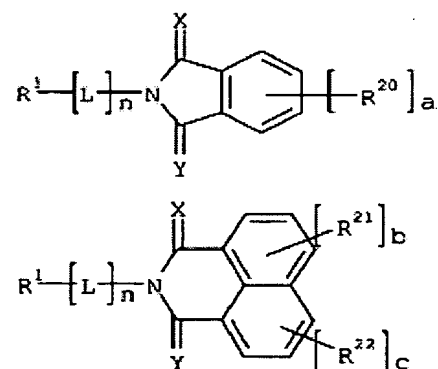
wherein n , e , f , g , h , p and q are independently 0 or 1,

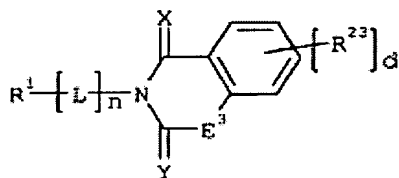
wherein e is 0 when E^1 is represented by O, S or NR^{15} , wherein f is 0 when and E^2 is represented by O, S or NR^{15} ,

wherein L , L^{11} , L^{12} , L^{13} and L^{14} are independently a linking group, and

wherein one of the groups selected from R^1 , R^{15} , R^{16} , R^{17} , R^{18} and R^{19} represents the phenolic monomeric unit and the remaining groups represent a terminal group.

7. (Currently Amended) [[A]] The polymer according to claim 1 wherein the group A has one of the following ~~formula~~ formulae





wherein X and Y are independently selected from O [[or]] and S,
wherein each R¹ [[,]] and R²⁰ to R²³ are is a terminal group [[,]] independently selected from hydrogen, an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group, halogen, -SO₂-NH-R²⁴, -NH-SO₂-R²⁷, -CO-NR²⁴-R²⁵, -NR²⁴-CO-R²⁷, -NR²⁴-CO-NR²⁵-R²⁶, -NR²⁴-CS-NR²⁵-R²⁶, -NR²⁴-CO-O-R²⁵, -O-CO-NR²⁴-R²⁵, -O-CO-R²⁷, -CO-O-R²⁴, -CO-R²⁴, -SO₃-R²⁴, -O-SO₂-R²⁷, -SO₂-R²⁴, -SO-R²⁷, -P(=O)(-O-R²⁴)(-O-R²⁵), -O-P(=O)(-O-R²⁴)(-O-R²⁵), -NR²⁴-R²⁵, -O-R²⁴, -S-R²⁴, -CN, -NO₂, -N(-CO-R²⁴)(-CO-R²⁵), -N-phthalimidyl, -M-N-phthalimidyl, [[or]] and -M-R²⁴, wherein M represents a divalent linking group containing 1 to 8 carbon atoms,
wherein R²⁴ to R²⁶ are independently selected from hydrogen [[or]] and an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group,
wherein R²⁷ is selected from an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl [[or]] and heteroaralkyl group,
wherein a and d are independently 0, 1, 2, 3 or 4,
wherein b and c are independently 0, 1, 2 or 3,
wherein E³ is selected from O, S, NR²⁸ [[or]] and R²⁹-[L¹⁵]_i-C-[L¹⁶]_j-R³⁰,
wherein L, L¹⁵ and L¹⁶ are independently a linking group, wherein n, i and j independently are 0 or 1,
and wherein one of the groups selected from R¹, R²⁰, R²¹, R²², R²³, R²⁸, R²⁹ and R³⁰ represents the phenolic monomeric unit and the remaining groups represent a terminal group.

8. (Currently Amended) [[A]] The polymer according to ~~any of the preceding claims~~ claim 1, wherein said polymer comprising a phenolic monomeric unit is a novolac, resol or polyvinylphenol.

9. (Currently Amended) A heat-sensitive lithographic printing plate precursor comprising a support having a hydrophilic surface and an oleophilic coating[[,]] provided on the hydrophilic surface, said coating comprising an infrared light absorbing agent and a polymer according to claim 1.

10. (Currently Amended) [[A]] The lithographic printing plate precursor according to claim 9, wherein said coating further comprises a dissolution inhibitor and wherein said precursor is a positive working lithographic printing plate precursor.

11. (Currently Amended) [[A]] The lithographic printing plate precursor according to claim 10, wherein said dissolution inhibitor is selected from the group consisting of

[[-]] an organic compound which comprises at least one aromatic group and a hydrogen bonding site, ~~and/or~~

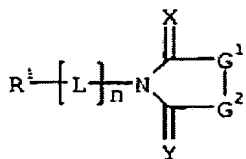
[[-]] a polymer or surfactant comprising siloxane or perfluoroalkyl units, and mixtures thereof.

12. (Canceled)

13. (Currently Amended) [[A]] The heat-sensitive lithographic printing plate precursor according to claim 9, wherein said coating further comprising a latent Brönsted acid and an acid-crosslinkable compound and wherein said precursor is a negative working lithographic printing plate precursor.

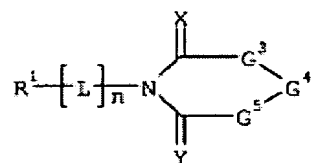
14. (Canceled)

15. (New) The heat-sensitive lithographic printing plate precursor according to claim 9 wherein the group A has the following formula



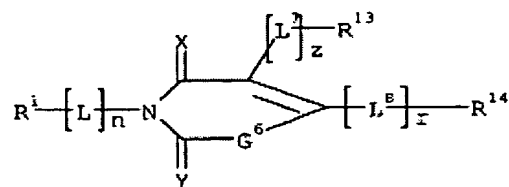
wherein X and Y are independently selected from O and S,
wherein G^1 and G^2 are independently selected from O, S, NR^4 and $R^5-[L^3]_t-C-[L^4]_u-R^6$, with the limitation that G^1 is not O or S when G^2 is O and that G^1 is not O or S when G^2 is NR^4 ,
wherein L, L^3 and L^4 are independently a linking group,
wherein n, t and u are independently 0 or 1,
and wherein one of the groups selected from R^1 , R^4 , R^5 and R^6 represents the phenolic monomeric unit and the remaining groups represent a terminal group.

16. (New) The heat-sensitive lithographic printing plate precursor according to claim 9 wherein the group A has the following formula



wherein X and Y are independently selected from O and S,
wherein G^3 to G^6 are independently selected from O, S, NR^7 and $R^8-[L^5]_v-C-[L^6]_w-R^9$ with the limitation that at least one group, selected from G^3 to G^6 , is $R^8-[L^5]_v-C-[L^6]_w-R^9$ and that two neighbouring groups, selected from G^3 to G^6 , are not represented by O and S, by O and NR^7 , by S and NR^7 or by O and O,
wherein L, L^5 and L^6 are independently a linking group, wherein n, v and w are independently 0 or 1,
and wherein one of the groups selected from R^1 , R^7 , R^8 and R^9 represents the phenolic monomeric unit and the remaining groups represent a terminal group.

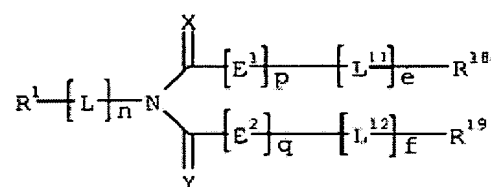
17. (New) The heat-sensitive lithographic printing plate precursor according to claim 9 wherein the group A has the following formula



wherein X and Y are independently selected from O and S,
wherein G is a group selected from O, S, NR^{10} and $R^{11}-[L^9]_x-C-[L^{10}]_y-R^{12}$,

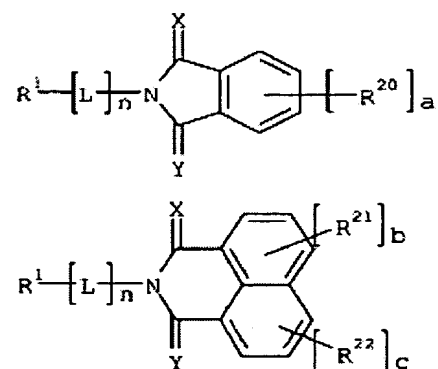
wherein L , L^7 , L^8 , L^9 and L^{10} are independently a linking group,
wherein n , x , y , z and r are independently 0 or 1,
and wherein one of the groups selected from R^1 , R^{10} , R^{11} , R^{12} , R^{13} and R^{14} represents the phenolic monomeric unit and the remaining groups represent a terminal group.

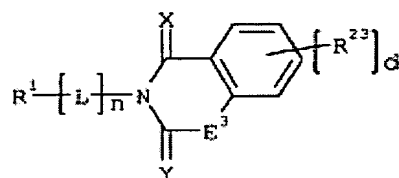
18. (New) The heat-sensitive lithographic printing plate precursor according to claim 9 wherein the group A has the following formula



wherein X and Y are independently selected from O and S ,
wherein E^1 and E^2 are independently selected from O , S , NR^{15} and $R^{16}-[L^{13}]_g-C-[L^{14}]_h-R^{17}$,
wherein n , e , f , g , h , p and q are independently 0 or 1, wherein e is 0 when E^1 is represented by O , S or NR^{15} , wherein f is 0 when E^2 is represented by O , S or NR^{15} ,
wherein L , L^{11} , L^{12} , L^{13} and L^{14} are independently a linking group,
and wherein one of the groups selected from R^1 , R^{15} , R^{16} , R^{17} , R^{18} and R^{19} represents the phenolic monomeric unit and the remaining groups represent a terminal group.

19. (New) The heat-sensitive lithographic printing plate precursor according to claim 9 wherein the group A has one of the following formulae





wherein X and Y are independently selected from O and S,
wherein each R^1 and R^{20} to R^{23} is a terminal group independently selected from hydrogen, an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group, halogen, $-\text{SO}_2-\text{NH}-R^{24}$, $-\text{NH}-\text{SO}_2-R^{27}$, $-\text{CO}-\text{NR}^{24}-R^{25}$, $-\text{NR}^{24}-\text{CO}-R^{27}$, $-\text{NR}^{24}-\text{CO}-\text{NR}^{25}-R^{26}$, $-\text{NR}^{24}-\text{CS}-\text{NR}^{25}-R^{26}$, $-\text{NR}^{24}-\text{CO}-\text{O}-R^{25}$, $-\text{O}-\text{CO}-\text{NR}^{24}-R^{25}$, $-\text{O}-\text{CO}-R^{27}$, $-\text{CO}-\text{O}-R^{24}$, $-\text{CO}-R^{24}$, $-\text{SO}_3-R^{24}$, $-\text{O}-\text{SO}_2-R^{27}$, $-\text{SO}_2-R^{24}$, $-\text{SO}-R^{27}$, $-\text{P}(=\text{O})(-\text{O}-R^{24})(-\text{O}-R^{25})$, $-\text{O}-\text{P}(=\text{O})(-\text{O}-R^{24})(-\text{O}-R^{25})$, $-\text{NR}^{24}-R^{25}$, $-\text{O}-R^{24}$, $-\text{S}-R^{24}$, $-\text{CN}$, $-\text{NO}_2$, $-\text{N}(-\text{CO}-R^{24})(-\text{CO}-R^{25})$, $-\text{N-phthalimidyl}$, $-\text{M-N-phthalimidyl}$, and $-\text{M}-R^{24}$, wherein M represents a divalent linking group containing 1 to 8 carbon atoms,
wherein R^{24} to R^{26} are independently selected from hydrogen and an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group,
wherein R^{27} is selected from an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl and heteroaralkyl group,
wherein a and d are independently 0, 1, 2, 3 or 4,
wherein b and c are independently 0, 1, 2 or 3,
wherein E^3 is selected from O, S, NR^{28} or $R^{29}-[\text{L}^{15}]_i-\text{C}-[\text{L}^{16}]_j-R^{30}$, wherein L, L^{15} and L^{16} are independently a linking group,
wherein n, i and j independently are 0 or 1,
and wherein one of the groups selected from R^1 , R^{20} , R^{21} , R^{22} , R^{23} , R^{28} , R^{29} and R^{30} represents the phenolic monomeric unit and the remaining groups represent a terminal group.

20. (New) The heat-sensitive lithographic printing plate precursor according to claim 15, wherein said coating further comprises a dissolution inhibitor and wherein said precursor is a positive working lithographic printing plate precursor.

21. (New) The heat-sensitive lithographic printing plate precursor according to claim 16, wherein said coating further comprises a dissolution inhibitor and wherein said precursor is a positive working lithographic printing plate precursor.

22. (New) The heat-sensitive lithographic printing plate precursor according to claim 17, wherein said coating further comprises a dissolution inhibitor and wherein said precursor is a positive working lithographic printing plate precursor.

23. (New) The heat-sensitive lithographic printing plate precursor according to claim 18, wherein said coating further comprises a dissolution inhibitor and wherein said precursor is a positive working lithographic printing plate precursor.

24. (New) The heat-sensitive lithographic printing plate precursor according to claim 19, wherein said coating further comprises a dissolution inhibitor and wherein said precursor is a positive working lithographic printing plate precursor.

25. (New) The heat-sensitive lithographic printing plate precursor according to claim 15, wherein said coating further comprising a latent Brönsted acid and an acid-crosslinkable compound and wherein said precursor is a negative working lithographic printing plate precursor.

26. (New) The heat-sensitive lithographic printing plate precursor according to claim 16, wherein said coating further comprising a latent Brönsted acid and an acid-crosslinkable compound and wherein said precursor is a negative working lithographic printing plate precursor.

27. (New) The heat-sensitive lithographic printing plate precursor according to claim 17, wherein said coating further comprising a latent Brönsted acid and an acid-crosslinkable compound and wherein said precursor is a negative working lithographic printing plate precursor.

28. (New) The heat-sensitive lithographic printing plate precursor according to claim 18, wherein said coating further comprising a latent Brönsted acid and an

acid-crosslinkable compound and wherein said precursor is a negative working lithographic printing plate precursor.

29. (New) The heat-sensitive lithographic printing plate precursor according to claim 19, wherein said coating further comprising a latent Brönsted acid and an acid-crosslinkable compound and wherein said precursor is a negative working lithographic printing plate precursor.

30. (New) The polymer according to claim 2, wherein said polymer comprising a phenolic monomeric unit is a novolac, resol or polyvinylphenol.

31. (New) The polymer according to claim 3, wherein said polymer comprising a phenolic monomeric unit is a novolac, resol or polyvinylphenol.

32. (New) The polymer according to claim 4, wherein said polymer comprising a phenolic monomeric unit is a novolac, resol or polyvinylphenol.

33. (New) The polymer according to claim 5, wherein said polymer comprising a phenolic monomeric unit is a novolac, resol or polyvinylphenol.

34. (New) The polymer according to claim 6, wherein said polymer comprising a phenolic monomeric unit is a novolac, resol or polyvinylphenol.

35. (New) The polymer according to claim 7, wherein said polymer comprising a phenolic monomeric unit is a novolac, resol or polyvinylphenol.

36. (New) A method for increasing the chemical resistance of a coating of a positive working heat-sensitive lithographic printing plate precursor against printing liquids and press chemicals, the method comprising providing a coating comprising:

a polymer according to claim 1,
an infrared absorbing agent, and

a dissolution inhibitor.

37. (New) A method for increasing the chemical resistance of a coating of a negative working heat-sensitive lithographic printing plate precursor against printing liquids and press chemicals, the method comprising providing a coating comprising:

- a polymer according to claim 1,
- a latent Brönsted acid, and
- an acid-crosslinkable compound.